



Figure 2: Schematic diagram of the variation of free energy with particle separation at higher salt concentrations showing the possibility of a secondary minimum.

Therefore to maintain the stability of the colloidal system, the repulsive forces must be dominant. How can colloidal stability be achieved? There are two fundamental mechanisms that affect dispersion stability (figure 3):

Steric repulsion - this involves polymers added to the system adsorbing onto the particle surface and
preventing the particle surfaces coming into close contact. If enough polymer adsorbs, the thickness of the
coating is sufficient to keep particles separated by steric repulsions between the polymer layers, and at those
separations the van der Waals forces are too weak to cause the particles to adhere.

 Electrostatic or charge stabilization - this is the effect on particle interaction due to the distribution of charged species in the system.

Each mechanism has its benefits for particular systems. Steric stabilization is simple, requiring just the addition of a suitable polymer. However it can be difficult to subsequently flocculate the system if this is required, the polymer can be expensive and in some cases the used polymer is undesirable e.g. when a ceramic slip is cast and sintered, the polymer has to be 'burnt out'. This causes shrinkage and can lead to defects.



Steric stabilization Electrostatic stabilization Figure 3: Types of colloidal stabilization.

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